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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL. NO.	10017805	FILING DATE	10/30/2001	CLASS	430	SUBCLASS	1752	EXAMINER	
**APPLICANTS: Lin Shun-Li; Hsu Wei-Hua; <i>yet</i>									
**CONTINUING DATA VERIFIED: <i>None yet</i>									
**FOREIGN APPLICATIONS VERIFIED: TAIWAN 90113271 07/28/2001 <i>yet</i>									
PG-PUB DO NOT PUBLISH <input type="checkbox"/> RE-TOING <input type="checkbox"/> Foreign priority claimed <input checked="" type="checkbox"/> Yes <input type="checkbox"/> No 35 USC 110 conditions met <input checked="" type="checkbox"/> Yes <input type="checkbox"/> No Verified and Acknowledged Examiner's initials <i>yet</i> TITLE: Photoresist with adjustable polarized light function and photolithography process using the photoresist UCLAT7243									

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg.
		Print Fig.	
		Application Examiner	
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	
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